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Magnetron Sputtering Process for Homogeneous Internal Coating of Hollow Cylinders

Gunar Kaune, Daniel Hagedorn, Frank Löffler

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Title of Paper:	Magnetron Sputtering Process for Homogeneous Internal
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Presenting Author:	Gunar Kaune
Full Mailing Address:	Physikalisch-Technische Bundesanstalt, Bundesallee 100,
	D-38116 Braunschweig, Germany
Telephone:	+49 531 592-5532
Fax:	+49 531 592-69-5532
E-Mail:	gunar.kaune@ptb.de

Corresponding Author:	Gunar Kaune
Telephone:	+49 531 592-5532
Fax:	+49 531 592-69-5532
E-Mail:	gunar.kaune@ptb.de

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